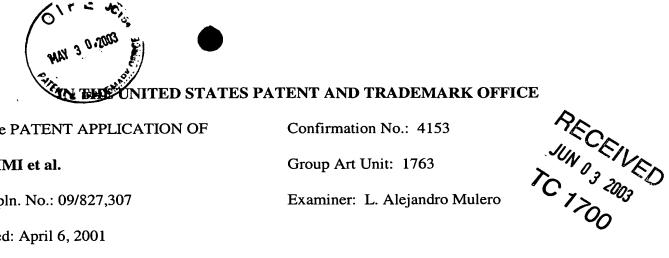
PATENT APPLICATION

A. ***	· 7 /			` <u>A</u>	PPLICATION
In re: PATENT APPLICATION	of:	Group Art U		26.1	
Inventor(s): OHMI et al.	927 207	Examiner: Atty. Dkt.	L. Alejandro P 0280043	Mulero EL00026CD	NC
	827,307 Serial No. ↑	Ally. DKI.	M#	Client Ref	<u></u>
Filed: April 6, 2001	Serial 140.	R	14211	Onene Rec	
Title: PLASMA PROCESSING	APPARATUS AND	RCE	DO NOT USE FO	R PROVISIONAL,	
PLASMA PROCESSING	METHOD	E	DIVISIONAL, CI		
	OIPE	<u>.</u> [APPLICATIONS, PATENTS	OR REEXAMINAT	
Mail Stop RCE	(TATEMIS		
Hon. Commissioner for Patents	MAY 3 0 2003	4	Date:	May 30, 2003	TEO
PO Box 1450		> /		, ·	III EII.
Alexandria, VA 22313-1450	A TRADEMACH			<u>`</u>	ON ON VE
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Sir:	OR CONTINUED I	EXAMINATI	ON (RCE) LINDE	CR RULE 114	/> "3"
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mi 11		_		-t action has been fil	lad arif
This application was <u>file</u> filed, it has been termina		95, is not aban	idoned, and no cou	rt action has been in	ed, of II
An issue fee <u>has not been</u> paid (<u>unless</u> a petition under Rule 313(c)(2) is also being filed see item 4 below).					
Prosecution has been closed as defined in Rule 114(b).					
Reply to any outstanding action must be enclosed or previously filed.					
This application is entitled under Rule 114 to withdrawal of any outstanding finality or of any allowance plus a new					
This application is entitled under action by the Examiner. Conside	Rule 114 to withdra	wal of any out	tstanding finality o	r of any allowance p	lus a new
evidence, but not appeal/reply br					ments, new
Please consider the following be					
Flease consider the following be	erore the next Officia	ii Action.			
1. Please ⊠ enter □ do n	ot enter the A	Amendment fi	led April 30, 200	3 (copy attached)	
2. The enclosed new Amendment					
3. Consider the arguments in the appeal brief filed and reply brief filed					
4. The issue fee has been pa			313(c)(2). See encl	osed petition.	
5. The enclosed Information		nt Cited Appln	□ For	eign Search Report/C	λ Δ
		лец Арріп		d Documents	<i>71</i> 1
6. Please suspend action un		period of	months (3 mos. M	ax) for which charge	the
required \$130 fee (fee co					
7. Petition is hereby made to exter cover the date this Request is fi	nd the original due date	e of March 30, 3	2003 to 300 (the two	(1 mo) \$110/\$55 2 mos) \$410/\$205	
month extension fee of \$410 les				3 mos) \$930/\$465	+ 300
been paid. PLEASE CHARG				•	
(see below)	L 17() (DOE) Eller	££ 121 ¢	750 (1	275 (
8. PLEASE CHARGE the Ru deficiency and any other fee				7(e) filing fee <u>Cannot</u>	
Account No. 03-3975 under		_		EE REQUIRED unless	
i .	09827307 C#	M#	adding claims	by box 2 Amendment	in which case
01 FC:1801 750.00 CH			cover this with	PAT-120.	
Pillsbury Winthrop LLP/					
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P.O. Box 10500	By Atty: Dale	\$ Lazar	I // R	eg. No. <u>28872</u>	
McLean, VA 22102	11/1	10 1 1 0	7///	 	_
	Sig:	MAVI		ax: (703) 905-2500	
(703) 905-2000			Т	el: (703) 905-2126)

Atty/Sec: DSL/mll

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In re PATENT APPLICATION OF

Confirmation No.: 4153

OHMI et al.

Group Art Unit: 1763

Appln. No.: 09/827,307

Examiner: L. Alejandro Mulero

Filed: April 6, 2001

Title: PLASMA PROCESSING APPARATUS AND PLASMA PROCESSING METHOD

April 30, 2003

Cupy #1313

AMENDMENT

Hon. Commissioner of Patents Washington, D.C. 20231

Sir:

In response to the Office Action mailed December 30, 2002, please amend the above identified application as follows:

IN THE CLAIMS:

Please enter amended claims 1 and 7 as follows:

- 1. (Twice Amended) A plasma processing apparatus comprising:
- a first electrode;
- a substrate configured to be subjected to a plasma, the substrate being positioned on the first electrode;
- a magnetic field generator configured to apply a static magnetic field to a surface of the substrate to which the plasma process is applied; and